

**Notice of References Cited**

Application/Control No.

09/975,630

Applicant(s)/Patent Under  
Reexamination  
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Examiner

Leonardo Andújar

Art Unit

2826

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**U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-5,468,993	11-1995	Tani, Koji	257/676
	B	US-5,973,554	10-1999	Yamasaki et al.	327/564
	C	US-			
	D	US-			
	E	US-			
	F	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

**FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Wolf et al., Silicon Processing for the VLSI Era, Lattice Press, volume 1, pages 857-858.
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
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